# Forschungsfabrik Mikroelektronik Deutschland

Fraunhofer Group for Microelectronics in Cooperation with Leibniz Institutes FBH and IHP









Design & Design Methods

#### **Component Design**

Application specific active and passive component design

#### Package & System Design

 Design under constraints – functional safety, reliability, harsh environment, yield,...

#### Prototyping

Hardware-in-the-loop concepts, HW/SW co-design

#### **Design Methods**

Automated design tools for component, module and system development





Materials & Processes Devices & Components

#### Materials

• Si, SiGe, Piezo Materials, Metal-Dichalcogenides, CNT, Graphene,

#### Processes

- 200mm complete BiCMOS/CMOS lines, 300mm FDSOI material and process evaluation line
- Dielectric stacks, BEOL Modules
- Epitaxy, Implantation, advanced etching, ALD

#### **Devices and Components**

- CNT FETs...
- High Capacitance Capacitors
- Memories, NVM memories



#### **Heterogeneous Integration**

- CMOS wafer connection technology (MEMS/NEMS),
- Memory, CPU, FPGA (Single- & Multi Chip) Packaging advanced packaging,
- Advanced Substrate / Interposer rigid organic, Si, Fan-out molding,
- Housing

Hetero-geneous

Integration / SiP





Characterization, Test & Reliability

#### **Materials and Devices**

 Nondestructive examination of materials and devices, Accelerated lifetime testing and failure analysis, electrical test of semiconductor devices, Device degradation

#### **Analysis and Test**

 Automated in-line process monitoring, test of Analog-mixed signal circuits and digital circuits

### Reliability

 Device and system/package test under multiple stress scenarios, Combined load testing, lifetime assessments, thermal cycling, Wafer level reliability tests, thermo-electrical and thermos - mechanical reliability.

